<table>
<thead>
<tr>
<th>Title</th>
<th>Atomic-scale quantification of charge densities in two-dimensional materials</th>
</tr>
</thead>
<tbody>
<tr>
<td>Author(s)</td>
<td>Müller-Caspary, Knut; Duchamp, Martial; Rösner, Malte; Migunov, Vadim; Winkler, Florian; Yang, Hao; Huth, Martin; Ritz, Robert; Simson, Martin; Ihle, Sebastian; Soltau, Heike; Wehling, Tim; Dunin-Borkowski, Rafal E.; Van Aert, Sandra; Rosenauer, Andreas</td>
</tr>
<tr>
<td>Date</td>
<td>2018</td>
</tr>
<tr>
<td>URL</td>
<td><a href="http://hdl.handle.net/10220/46424">http://hdl.handle.net/10220/46424</a></td>
</tr>
<tr>
<td>Rights</td>
<td>© 2018 American Physical Society (APS). This paper was published in Physical Review B and is made available as an electronic reprint (preprint) with permission of American Physical Society (APS). The published version is available at: [<a href="http://dx.doi.org/10.1103/PhysRevB.98.121408">http://dx.doi.org/10.1103/PhysRevB.98.121408</a>]. One print or electronic copy may be made for personal use only. Systematic or multiple reproduction, distribution to multiple locations via electronic or other means, duplication of any material in this paper for a fee or for commercial purposes, or modification of the content of the paper is prohibited and is subject to penalties under law.</td>
</tr>
</tbody>
</table>
Atomic-scale quantification of charge densities in two-dimensional materials

Knut Müller-Caspary,1,2,3,* Martial Duchamp,3,4 Malte Rösner,5,6,7 Vadim Migunov,3 Florian Winkler,3 Hao Yang,7 Martin Huth,3 Robert Ritz,3 Martin Simson,8 Sebastian Ihle,3 Heike Soltau,8 Tim Wehling,5,6 Rafał E. Dunin-Borkowski,3 Sandra Van Aert,1 and Andreas Rosenauer2
1EMAT, Universiteit Antwerpen, Groenenborgerlaan 171, B-2020 Antwerpen, Belgium
2IFP, Universität Bremen, Otto-Hahn-Allee 1, 28359 Bremen, Germany
3Ernst Ruska-Centre for Microscopy and Spectroscopy with Electrons and Peter Grünberg Institute, Forschungszentrum Jülich, 52425 Jülich, Germany
4School of Materials Science and Engineering, Nanyang Technological University, 50 Nanyang Avenue, Singapore 639798, Singapore
5ITP, Universität Bremen, Otto-Hahn-Allee 1, 28359 Bremen, Germany
6BCCMS, Universität Bremen, Am Fallturm 1, 28359 Bremen, Germany
7Department of Physics and Astronomy, University of Southern California, Los Angeles, California 90089-0484, USA
8PNDetector GmbH, Otto-Hahn-Ring 6, 81739 München, Germany

(Received 9 May 2018; published 24 September 2018)

The charge density is among the most fundamental solid state properties determining bonding, electrical characteristics, and adsorption or catalysis at surfaces. While atomic-scale charge densities have as yet been retrieved by solid state theory, we demonstrate both charge density and electric field mapping across a mono-/bilayer boundary in 2D MoS2 by momentum-resolved scanning transmission electron microscopy. Based on consistency of the four-dimensional experimental data, statistical parameter estimation and dynamical electron scattering simulations using strain-relaxed supercells, we are able to identify an AA-type bilayer stacking and charge depletion at the Mo-terminated layer edge.

DOI: 10.1103/PhysRevB.98.121408

The discovery that mechanical, thermal, optical, and electrical properties of 2D materials such as graphene, Xenes (silicene, germanene), or transition metal dichalcogenides (TMDs, e.g., MoS2, WSe2) drastically differ from their bulk counterparts evoked enormous attention of both fundamental and applied research. The dominant route to get an atomistic understanding of bonding, conductance, band gaps, or adsorption or catalysis at surfaces. While atomic-scale charge densities have as yet been retrieved by solid state theory, we demonstrate both charge density and electric field mapping across a mono-/bilayer boundary in 2D MoS2 by momentum-resolved scanning transmission electron microscopy. Based on consistency of the four-dimensional experimental data, statistical parameter estimation and dynamical electron scattering simulations using strain-relaxed supercells, we are able to identify an AA-type bilayer stacking and charge depletion at the Mo-terminated layer edge.
FIG. 1. Atomic electric field measurement. (a) Interaction of an electron wave (amplitude: black, phase: red) with the projected potential $V_P$ and electric field $\vec{E}_P$ of an atom. (b) Ronchigram acquired with 250 $\mu$s frame time near a Mo site. The number of detected electrons is color coded. (c) Momentum transfer (red) and projected electric field $\vec{E}_m$ (blue) determined from the Ronchigram in (c).

charge density $\rho_m$ is obtained from Maxwell’s equations,

$$\rho_m(\vec{R}) = \varepsilon_0 \text{div}_\perp \vec{E}_m(\vec{R}) = [w \circ (\rho_P \ast I_0)](\vec{R}),$$

(2)

and quantifies the projected charge density with the spatial resolution corresponding to the ultimate limit set by the microscope [15].

We used the pnCCD [10,14] camera with a frame rate of 4 kHz to record the central parts of the diffraction patterns (Ronchigrams) on a 256$^2$ STEM raster employing an aberration-corrected STEM instrument operated at 80 kV to avoid specimen damage [15]. Figure 1(b) depicts an example Ronchigram recorded close to a Mo atom. Although the electron fluence was kept low at approximately $5.5 \times 10^5$ electrons/Å$^2$, the redistribution of intensity due to the atomic electric field is obvious. Its first moment yields the momentum transfer $\langle \vec{p}_\perp \rangle$ depicted in red in Fig. 1(c) with a modulus of 0.18 h nm$^{-1}$. This corresponds to the measured electric field $\vec{E}_m$ (blue) with a magnitude of 114 V calculated using Eq. (1). The momentum is given in units of Planck’s constant $h$ and the measured electric field in volts as it involves a projection operation through $\vec{E}_P$, according to Eq. (1).

Figure 2(a) depicts the atomically resolved electric field $\vec{E}_m$ measured across an area of 4 × 4 nm. This region is of particular interest because it contains a mono-/bilayer (ML/BL) boundary, as will be confirmed by simulations below. It is furthermore consistent with atom counting results using a statistics-based method [16–18] to evaluate scattering cross sections [15].

Field averages from the ML and BL have been calculated by a unit cell segmentation of the data and subsequent averaging involving a geometric transform as to the average cell geometry. The results are depicted in Fig. 2(b) with atomic sites indicated. Using Eq. (2), the charge density $\rho_m$ in Fig. 2(c) was calculated from Fig. 2(a) with ML and BL averages in Fig. 2(d). In both the ML and the BL we observe the periodicity of the hexagonal MoS$_2$ lattice and individual atomic sites in Figs. 2(c) and 2(d). Note that the measured electric field vanishes at atomic sites as seen from the structural model imposed on the averaged cells in Fig. 2(b). This is reasonable because the measured field involves the convolution of the projected electric field $\vec{E}_P$ with the probe intensity $I_0$ [7].

Interestingly the electric fields in the ML and the BL look very similar concerning their shape as can be inferred from the color sequence around an atom, but the field magnitudes in the BL are higher. This points at a double-monolayer-type stacking referred to as AA [19] or 3R-like [20], as investigated below. The ML/BL edge region shows a different field distribution which is indicative for a particular edge termination determined hereafter. As to the charge density in Figs. 2(c) and 2(d) we find positive values at atomic sites owing to the (screened) nuclear charge surrounded by negative values because of the electronic contributions. In the boundary region the charge density variations appear weaker than in the ML or BL. We emphasize that both electric field and charge density are mapped directly, without input of structure or chemistry, in contrast to former studies [21–23]. Furthermore no complex reconstruction procedure is involved such as for ptychography.
The data of Fig. 2 is now investigated in more detail to explore whether the precision of our charge density mapping allows us to draw conclusions about the stacking sequence of the BL and the termination at the ML/BL edge, solely from the charge density results. To this end, supercells with different stacking sequences and edge terminations have been created, strain relaxed by DFT [2,3] and then used as an input for STEM multislice [27] simulations particularly accounting for partial spatial coherence and specimen tilt. The analysis of the stacking is presented in Fig. 3 with the different stacking configurations illustrated in (a), simulated electric fields in (b), and charge densities in (c). Added as a plausibility check, the ML simulation in Fig. 3 (top) is in remarkable quantitative agreement with its experimental counterparts in Figs. 2(b) and 2(d), bearing in mind that the color scales of Figs. 2 and 3 are identical. Note that the actual specimen tilt of 7.5° around the axis indicated in (b), top, was accounted for [15]. The stacking terminology was adopted from Ref. [19] with the Ramsdell notation in brackets where applicable.

The AB sequence for the BL stacking can immediately be rejected by comparison with Figs. 2(b) and 2(d). Distinguishing between AA and AA′ is more challenging when considering only the electric fields. A more obvious decision is made from the charge densities in Fig. 3(c) of which the AA variant exhibits an asymmetric dumbbell similar to the experiment in Fig. 2(d) but contrary to the AA′ stacking. The asymmetry becomes clear from the structural model since all atomic columns will have identical projected potentials for the AA′ case. To illustrate this explicitly, Fig. 3(d) shows the integrated charge density profiles across the dumbbell marked by the dashed rectangles in Fig. 3(c). Indeed the AA stacking model represents the experimental data best concerning both the asymmetric character and the magnitude. Finally, Fig. 3(e) compiles simulation and experiment for both the ML and the AA-stacked BL at the same color scale, exhibiting perfect agreement within the experimental precision imposed by counting statistics.

The violation of inversion symmetry as seen from the projected charge density for the BL has important consequences on the optical properties. Since the AA-stacked bilayer can be considered a double monolayer, it exhibits twice the nonlinear susceptibility compared to a ML and shows strong spin- and valley selective circular dichroism [20]. However, the AA stacking is one variant among several others that have been observed, each constituting a local energetic minimum and unique optical properties [19,20,28]. That the present BL can take a stacking sequence that does not correspond to the global energetic minimum can be explained by the mechanical stress introduced during exfoliation and by the fact that the BL flake is kept fixed by surrounding (multi)layer steps or amorphous contamination.

Concerning the termination of the BL edge, Fig. 4(a) shows the sulfur dimer (S₂), sulfur monomer (S₁), and molybdenum monomer (Mo₁) configurations. The differences become most obvious in average charge density profiles across the ML/BL boundary calculated in the region indicated by the dashed rectangle in Fig. 2(c). Experimentally, a charge density oscillation of up to ±9 cm⁻² in the BL and ±6.5 cm⁻² in the ML are observed as shown at the top of Fig. 4(b). Interestingly, it drops to [−4.5 ... 3] cm⁻² at the edge. The three simulated counterparts drawn at the bottom of Fig. 4(b) have been obtained by STEM multislice [27] simulations.
FIG. 4. Termination of the MoS$_2$ ML/BL edge. (a) Strain-minimized edge models used for the multislice simulations. (b) Experimental (top) charge density profile taken in the dashed region of Fig. 2(c). Below the simulated analogons are shown for the models in (a), indicating a Mo$_1$ termination.

using the experimental parameters and the structures from Fig. 4(a). The measured charge depletion is only observed for an edge terminated by a Mo monomer (black). However, simulation and experiment match nearly perfectly safely inside the ML/BL, while the Mo$_1$ simulation exhibits still slightly too high charge densities near the edge. This might be attributed to strain which is not taken into account in the simulation. In terms of Pythagorean sums of the differences to the experimental profile per pixel, we find 0.031, 0.024, and 0.021 cm$^{-2}$ for the S$_2$, S$_1$, and Mo$_1$ cases, respectively, so that the Mo termination is the most likely edge configuration. This demonstrates that this technique can be very valuable in future studies where the charge density is to be correlated, e.g., with catalytic or electrical properties. For example, Mo edges were found catalytically active [29,30] and exhibit metallic character [31] aside from the semiconducting nature of MoS$_2$.

To conclude, distinguishing features of an AA-stacked MoS$_2$ bilayer could be resolved by means of atomic-scale electric field and charge density mapping, which exhibit a violation of inversion symmetry. The assignment of a Mo termination to the mono-/bilayer edge, accompanied by a depleted charge density, demonstrates the sensitivity of the method. The presented study shows great promise to shed light on the atomic-scale electrical configuration of vacancies, dopant atoms, dislocations, stacking faults, and multilayer stacking in the growing family of 2D materials. Enhancing the precision further so as to be sensitive to bonding effects will surely dominate upcoming work, for which low-Z 2D materials such as N-doped graphene or BN would be interesting applications.

This concurrence of excellent momentum resolution, the quantum mechanical interpretation of 4D experimental data, aberration-corrected low-voltage STEM, and ultrafast electron detectors is fundamentally changing the scope of atomic-resolution solid state research, now allowing for atomic-scale charge density mapping without any prior knowledge of atomic species or sites.

K.M.-C. acknowledges funding from the Initiative and Network Fund of the Helmholtz Association (VH-NG-1317) within the framework of the Helmholtz Young Investigator Group moreSTEM at Forschungszentrum Jülich, Germany.


